

NOVA

NOVA SCHOOL OF
SCIENCE & TECHNOLOGY

DEPARTMENT
OF MATERIALS SCIENCE

FCT

Fundação para a Ciência e a Tecnologia
MINISTÉRIO DA CIÊNCIA, TECNOLOGIA E ENSINO SUPERIOR

CENIMAT
CENTRO DE INVESTIGAÇÃO DE MATERIAIS

i3N
INSTITUTO DE
NANOESTRUTURAS,
NANOMODELAÇÃO E
NANOFABRICAÇÃO

 **cemop**
CENTER OF EXCELLENCE IN MICROELECTRONICS
OPTOELECTRONICS AND PROCESSES **uninova**

Design of new intelligent materials and devices using nanotechnology

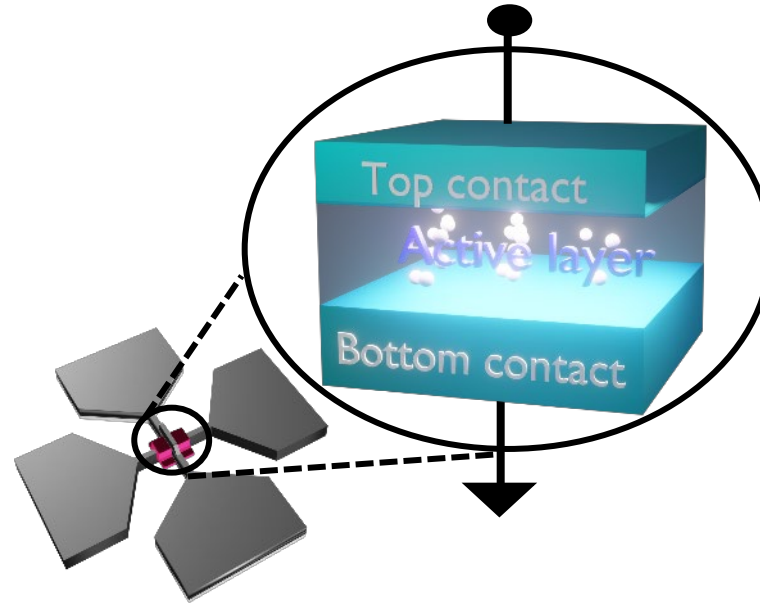
Asal Kiazadeh

Outline

- Overview of nanotechnology
- Role of nanotechnology in communication applications

Case Studies at CENIMAT/I3N:

- Memristor as artificial synapses
- Memristors as RF switch




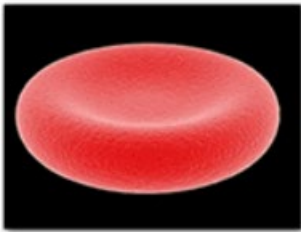
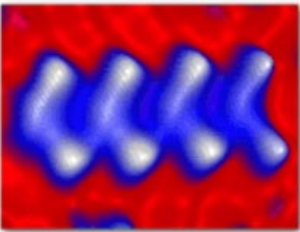
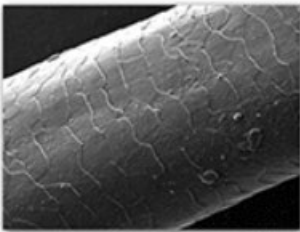


Adv. Mater. 2020, 2004328 (review article)

Nanotechnology in developing intelligent materials

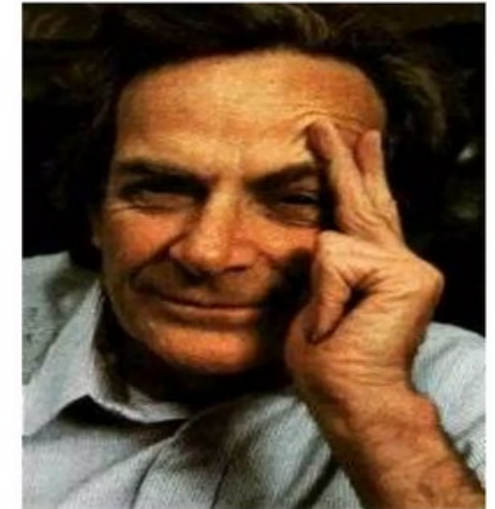
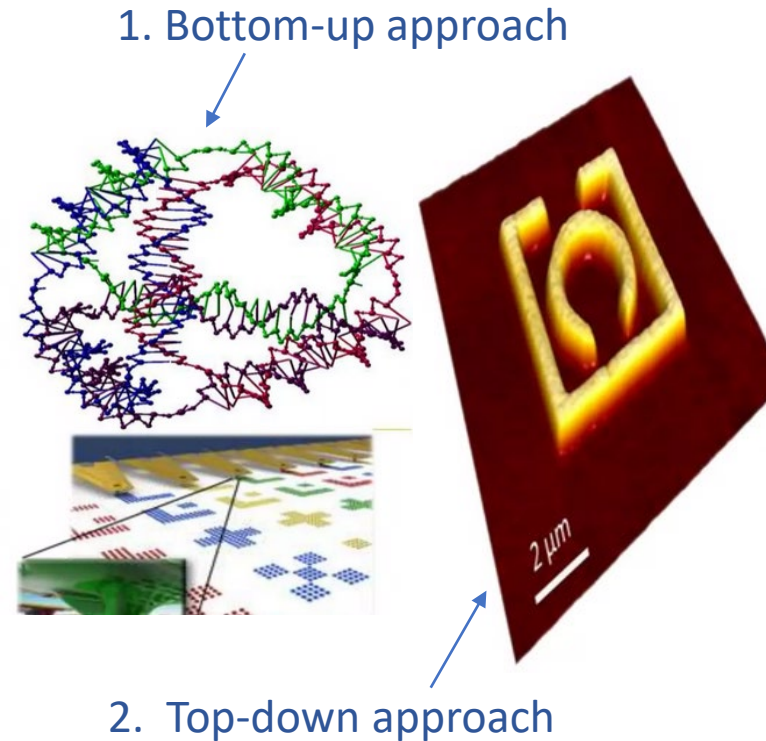
Nanotechnology is a branch of science and technology that deals with materials and devices at the nanoscale, typically involving dimensions less than 100 nanometers.

- A nanometer is one billionth of a meter.

The concept was presented in 1956 by the famous professor of Physics Richard Feynman.

 <p>1 nanometer = 10^{-9} meters = 0.000000001 meters (1 billionth)</p>	 <p>A human red blood cell is about 7,000 nm wide</p>	 <p>These 4 pairs of molecules are less than 1 nm wide</p>
 <p>A human hair is 50,000 to 100,000 nm thick</p>	 <p>Your finger-nails grow about 1 nm per second</p>	 <p>1 nm is to a tennis ball what a tennis ball is to the Earth</p>

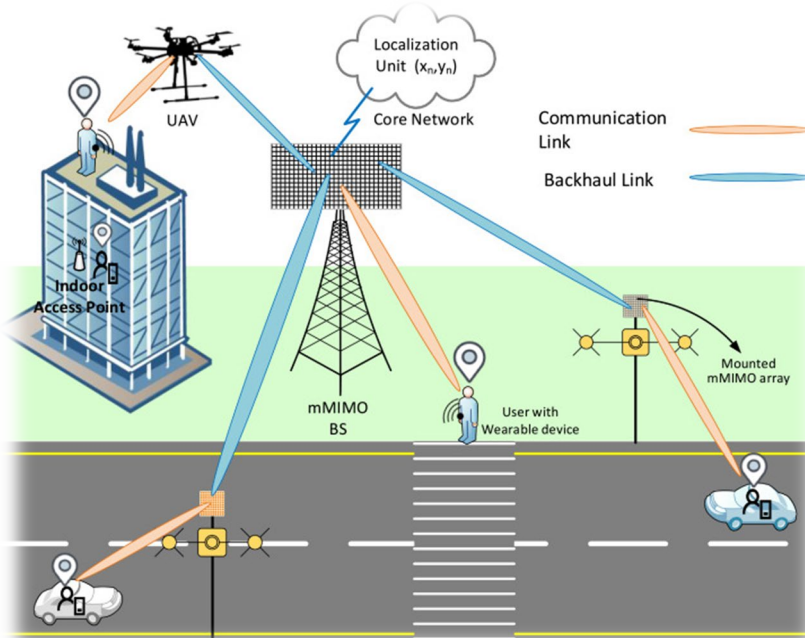
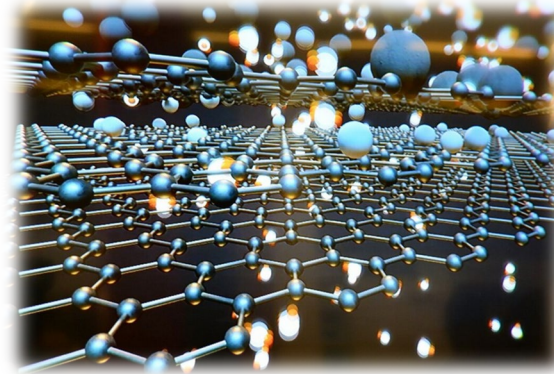
https://www.nanowerk.com/nanotechnology/introduction/introduction_to_nanotechnology_1.php



THERE'S PLENTY OF ROOM AT THE BOTTOM

Nanotechnology can provide several benefits to communication

- ❑ Miniaturization and Integration
- ❑ Enhanced Data Transfer Rates
- ❑ Intelligent Nanomaterials for Antennas
- ❑ Advanced Materials for THz Communication
- ❑ Energy-Efficient Devices
- ❑ Nano-sensors for Network Monitoring
- ❑ Smart Surfaces for Signal Enhancement
- ❑ Flexible and Wearable Devices,...



Complex computations is involved in **Multiple Input Multiple Output (MIMO)** signal processing.

Massive MIMO, <https://doi.org/10.1016/j.adhoc.2020.102353>

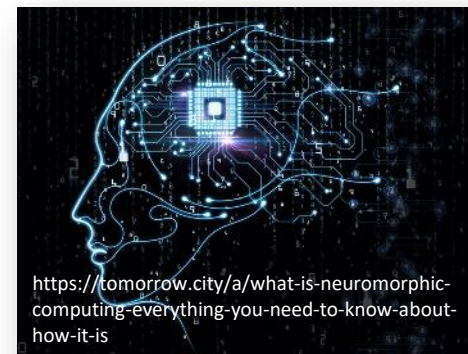
<https://rbmigroupofinstitutions.wordpress.com/2021/08/31/>

Power-efficient computation system

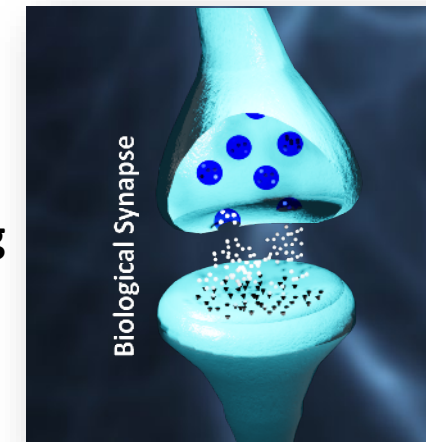
Data centers



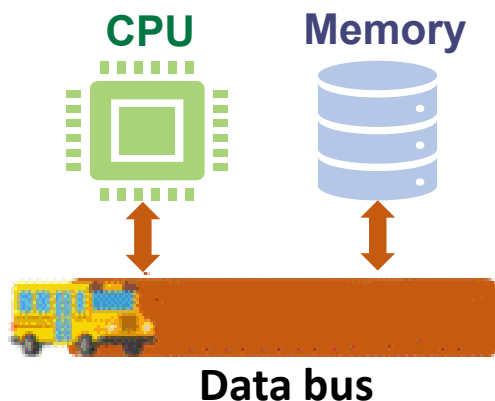
The cloud



Neuromorphic computing



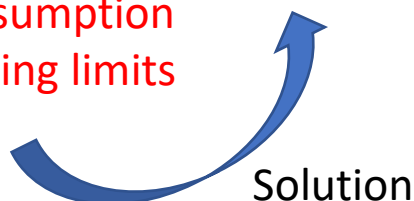
Von Neumann architecture and CMOS technology



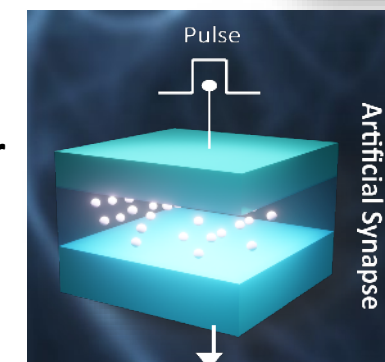
Latency issues
Privacy issues
Huge power consumption
Approaching scaling limits

Real time data analysis
In-memory computation
Power-efficient systems
High density information

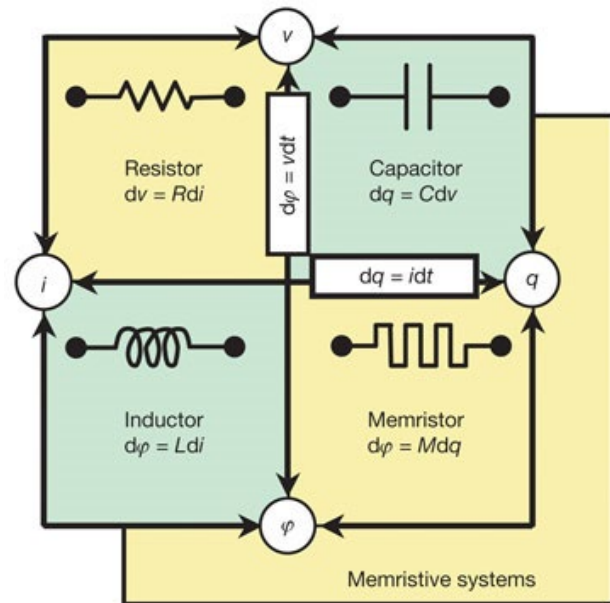
Based on emulating biological neurons synapses



Memristor



LETTERS

The missing memristor foundDmitri B. Strukov¹, Gregory S. Snider¹, Duncan R. Stewart¹ & R. Stanley Williams¹

Leon Ong Chua is an American electrical engineer and computer scientist. He is a professor in the electrical engineering and computer sciences department at the **University of California, Berkeley**.



It took about **40 years** for the memristor to be implemented in a physical form!

Thanks to Nanotechnology

Richard **Stanley Williams** is research scientist in the field of nanotechnology and a Senior Fellow and the founding director of the Quantum Science Research **Laboratory** at **Hewlett-Packard (HP)**.

Analog MVM machine: Very energy efficient, fast and compact

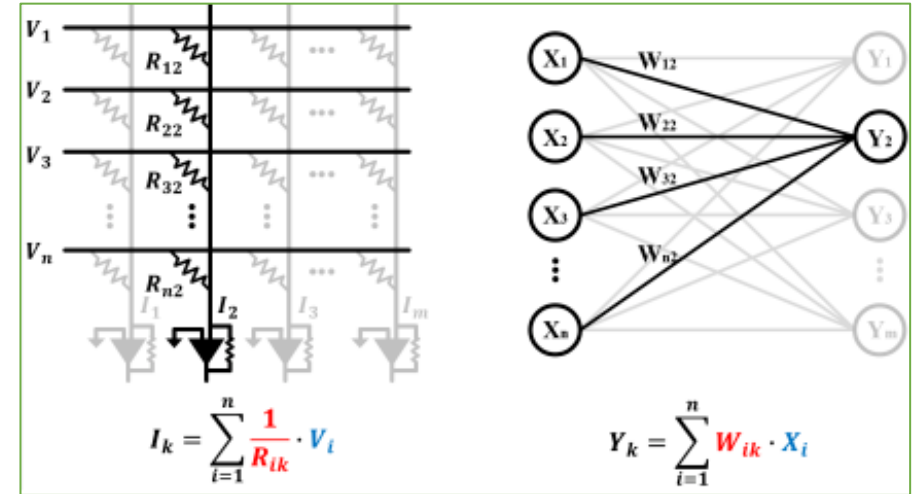
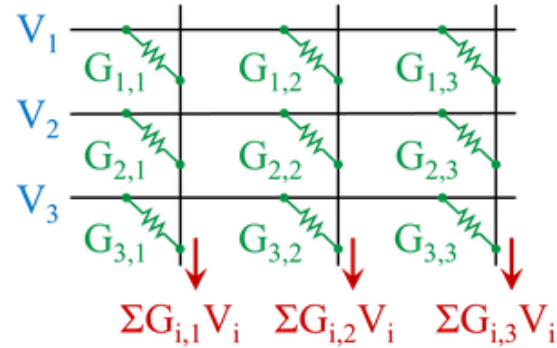
A physical system directly mapping the AI algorithm

Mathematical

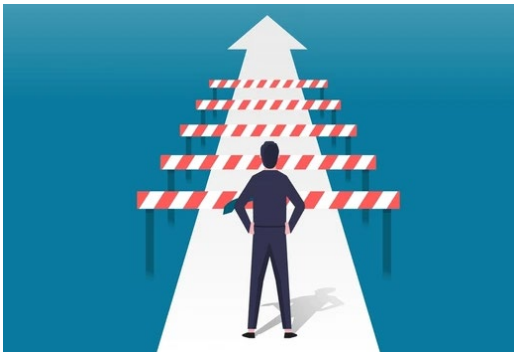
$$y = Wx$$

$$\begin{bmatrix} X_1 \\ X_2 \\ X_3 \end{bmatrix} \begin{bmatrix} W_{1,1} & W_{1,2} & W_{1,3} \\ W_{2,1} & W_{2,2} & W_{2,3} \\ W_{3,1} & W_{3,2} & W_{3,3} \end{bmatrix} = \begin{bmatrix} \sum W_{i,1} X_i & \sum W_{i,2} X_i & \sum W_{i,3} X_i \end{bmatrix}$$

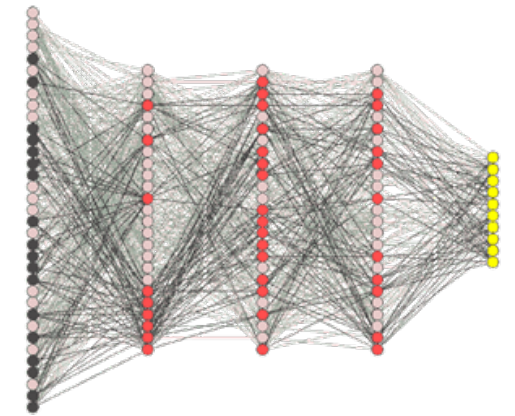
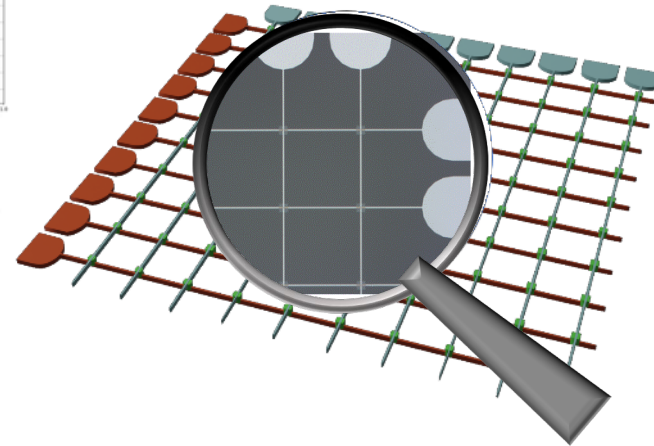
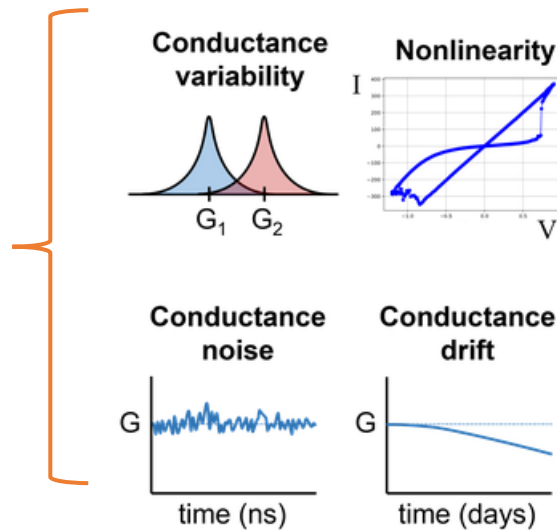
Electrical



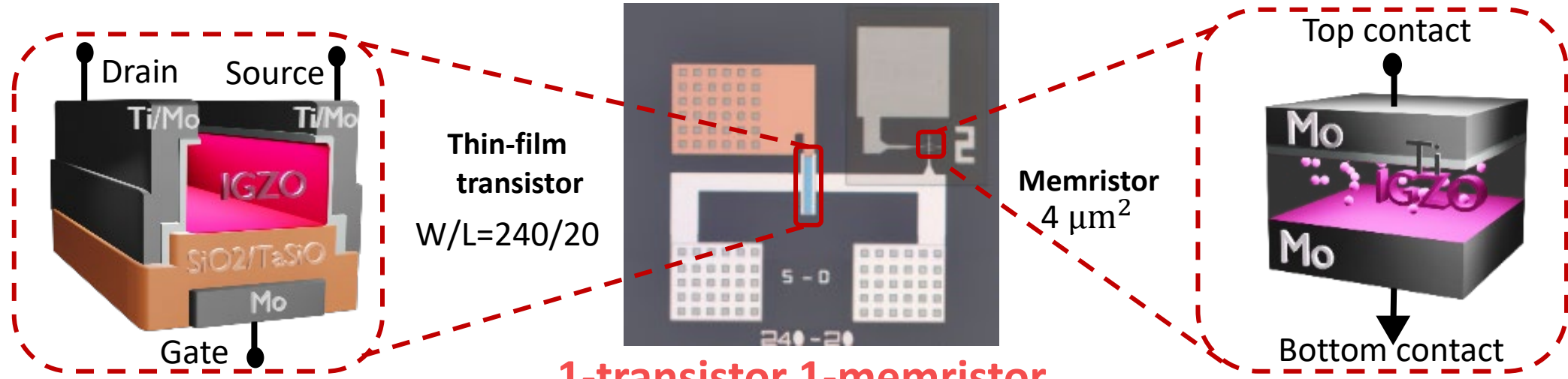
Challenges of ANN hardware



MVM: matrix vector multiplication
ANN: Artificial neural network

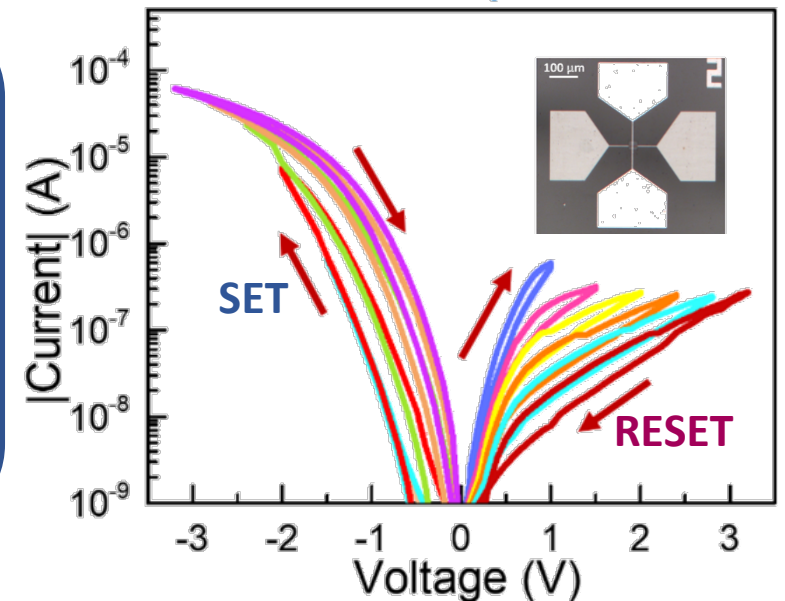
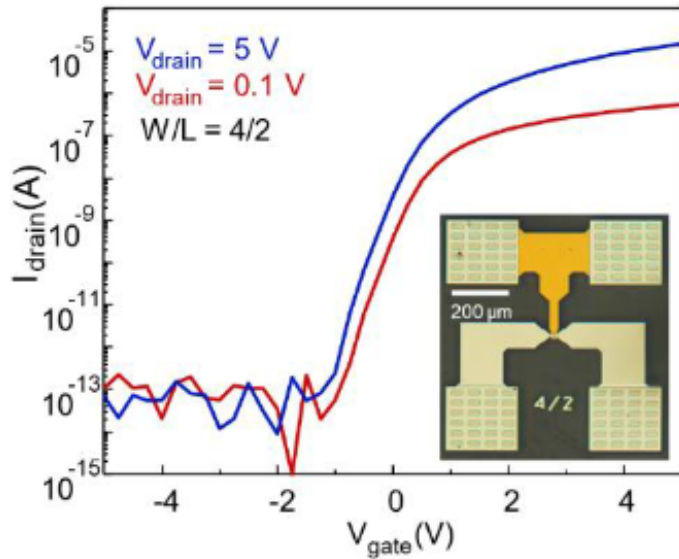


IGZO memristor devices & its integration



1-transistor 1-memristor

- TFT's S/D electrode is **directly connected** to memristor's top contact, All Mo electrodes
- Fabrication: **conventional clean-room techniques**: RF magnetron sputtering depositions and photolithography
- Optimization of layers for **compatibility** with both devices.

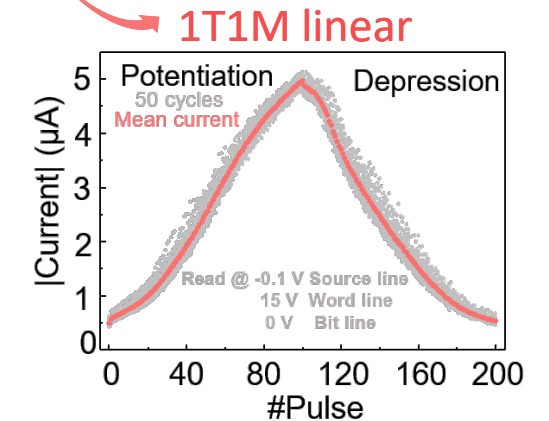
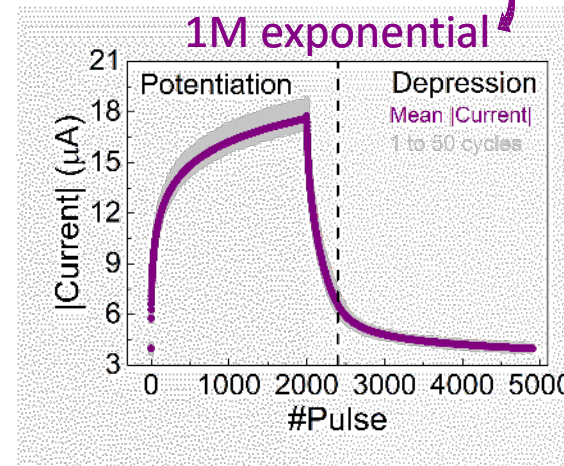
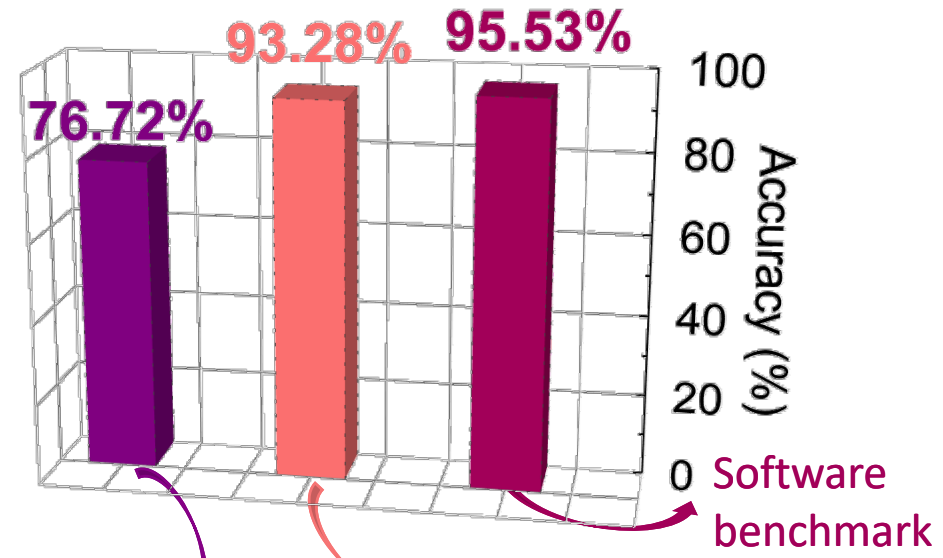
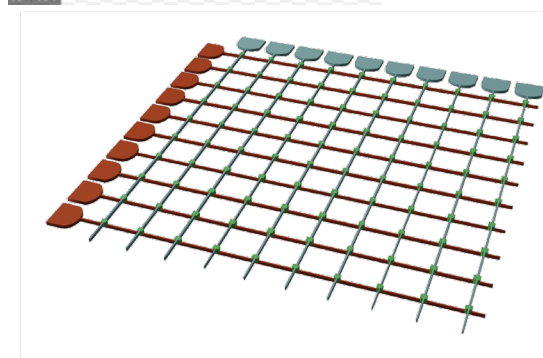
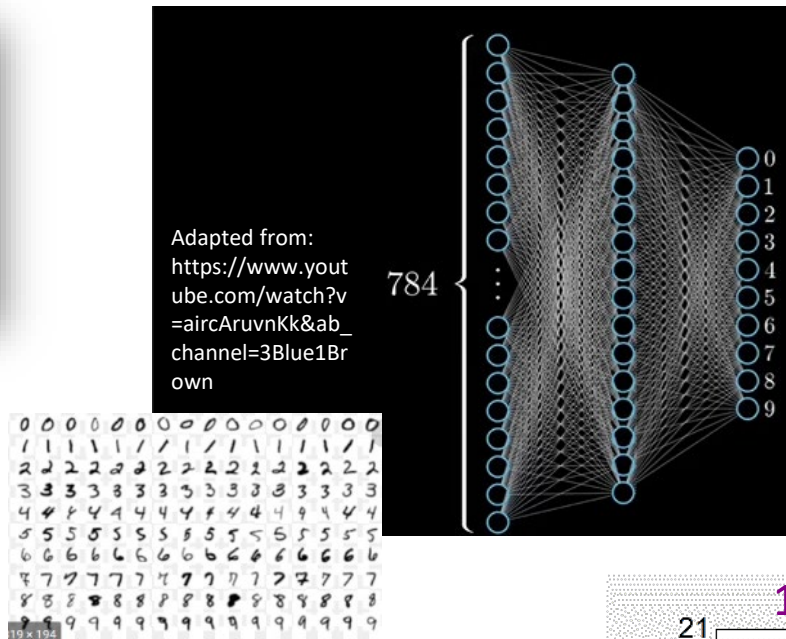


Adv. Electron.Mater.2022, 8, 2200642

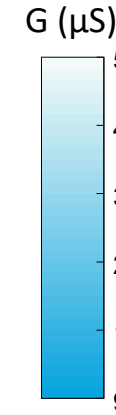
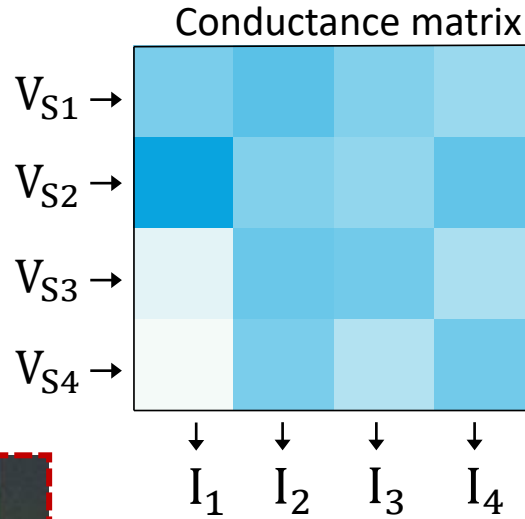
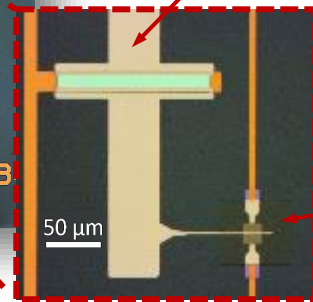
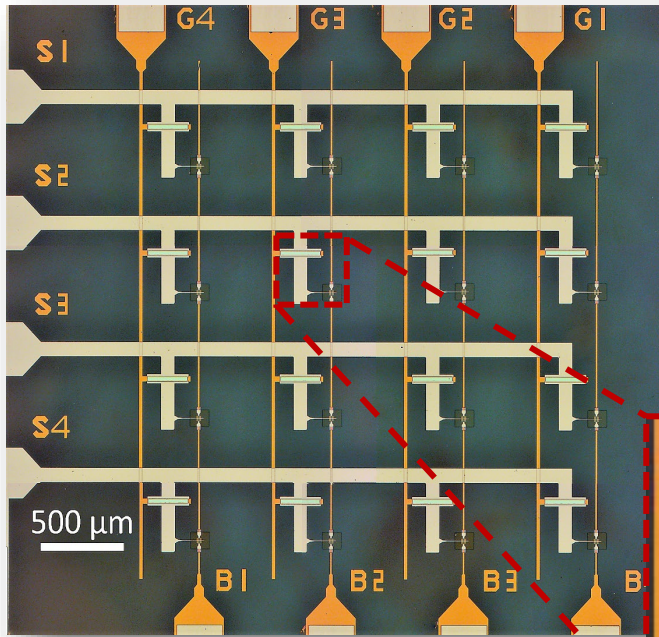
Pattern recognition applications: CrossSIM simulation



- Deep neural networks for pattern recognition of the **MNIST Handwritten Digits** with original data of 28x28 pixels
- Network architecture is multilayer perceptron (MLP) with structure 784x30x10
- Training algorithm is Gradient Descent
- The impact of non-linearity, asymmetry, C2C variability and noise can be accurately considered in CrossSim.



Vector-matrix multiplications



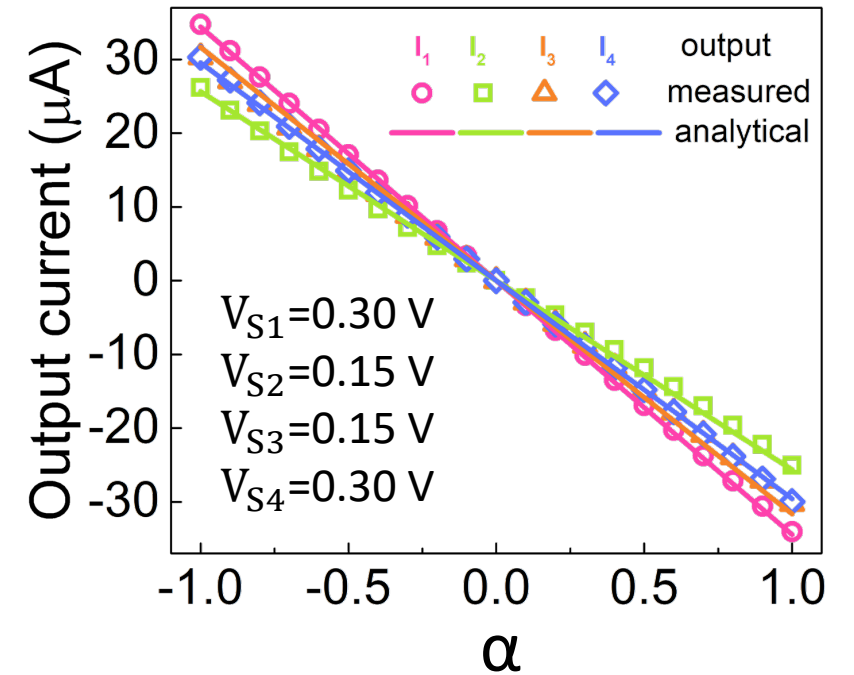
$$\alpha \begin{bmatrix} V_{S1} \\ V_{S2} \\ V_{S3} \\ V_{S4} \end{bmatrix} \times \begin{bmatrix} G_{1,1} & G_{1,2} & G_{1,3} & G_{1,4} \\ G_{2,1} & G_{2,2} & G_{2,3} & G_{2,4} \\ G_{3,1} & G_{3,2} & G_{3,3} & G_{3,4} \\ G_{4,1} & G_{4,2} & G_{4,3} & G_{4,4} \end{bmatrix}$$

$$= (V_{S1} G_{1,1} + V_{S2} G_{2,1} + V_{S3} G_{3,1} + V_{S4} G_{4,1}) + (\dots) + (\dots) + (\dots)$$

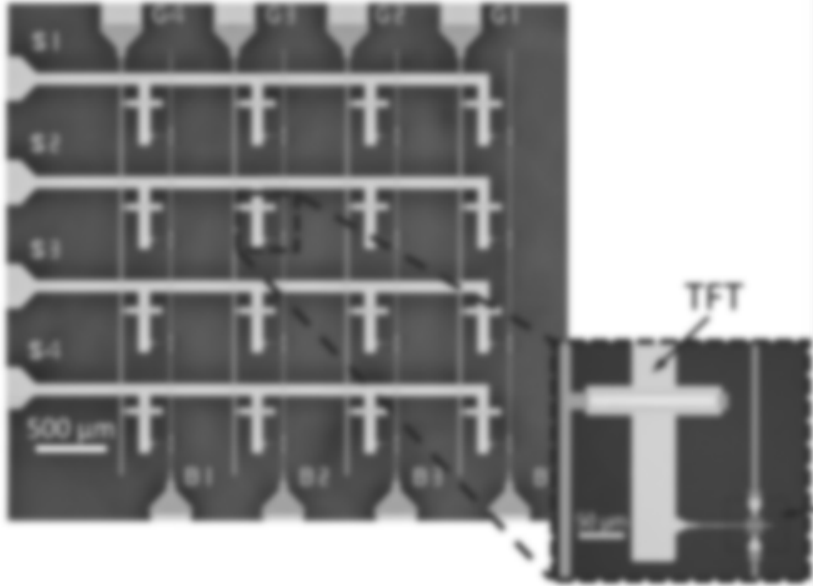
$$= [I_1 \quad I_2 \quad I_3 \quad I_4]$$

Active crossbars

✓ 1T1M solves the sneak-path currents effect.

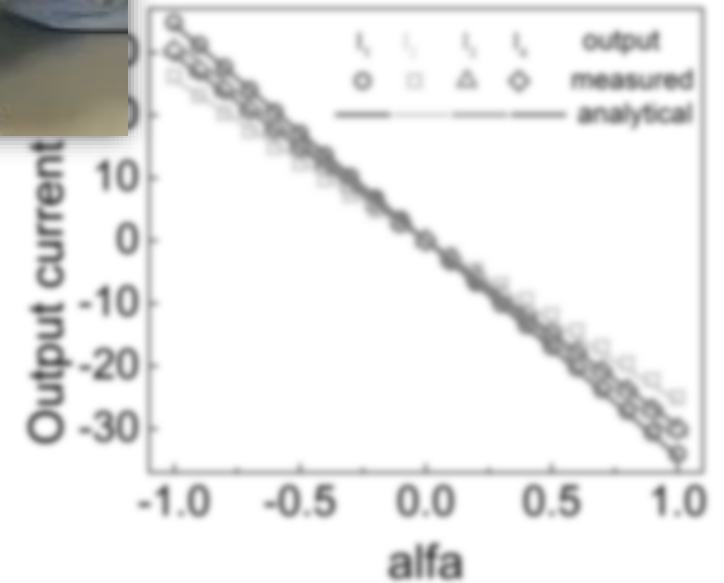


Flexible active crossbars



$$\begin{bmatrix} V_{S1} \\ V_{S2} \\ V_{S3} \\ V_{S4} \end{bmatrix} \times \begin{bmatrix} G_{1,1} & G_{1,2} & G_{1,3} & G_{1,4} \\ G_{2,1} & G_{2,2} & G_{2,3} & G_{2,4} \\ G_{3,1} & G_{3,2} & G_{3,3} & G_{3,4} \\ G_{4,1} & G_{4,2} & G_{4,3} & G_{4,4} \end{bmatrix}$$

$$= [I_1 \quad I_2 \quad I_3 \quad I_4]$$



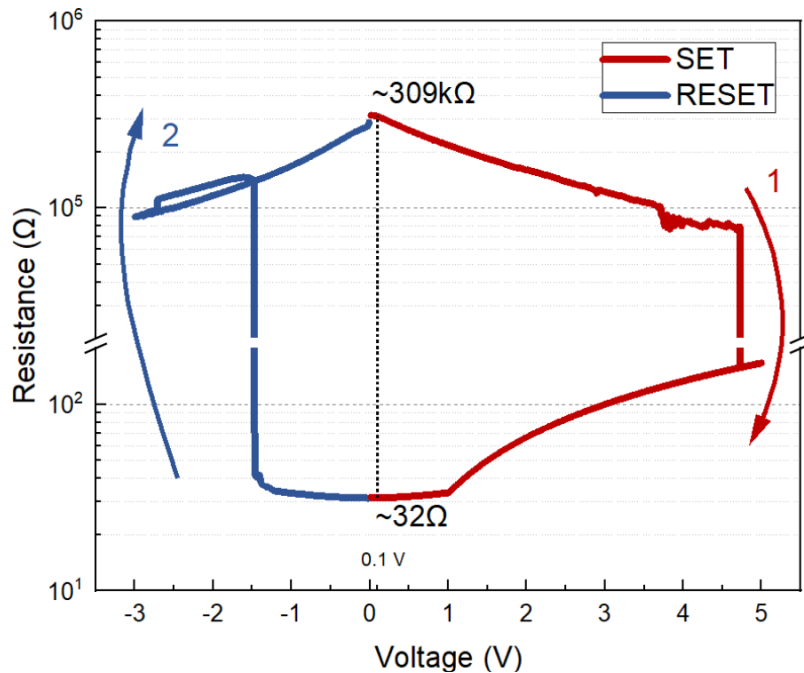
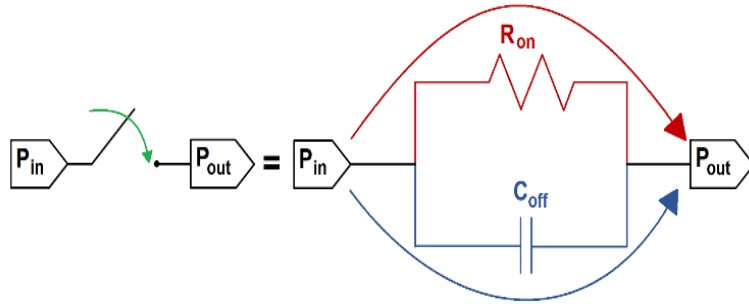
Flexible artificial neural network



Flexible! Built on a polyimide substrate.

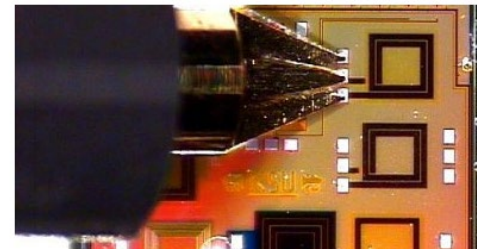
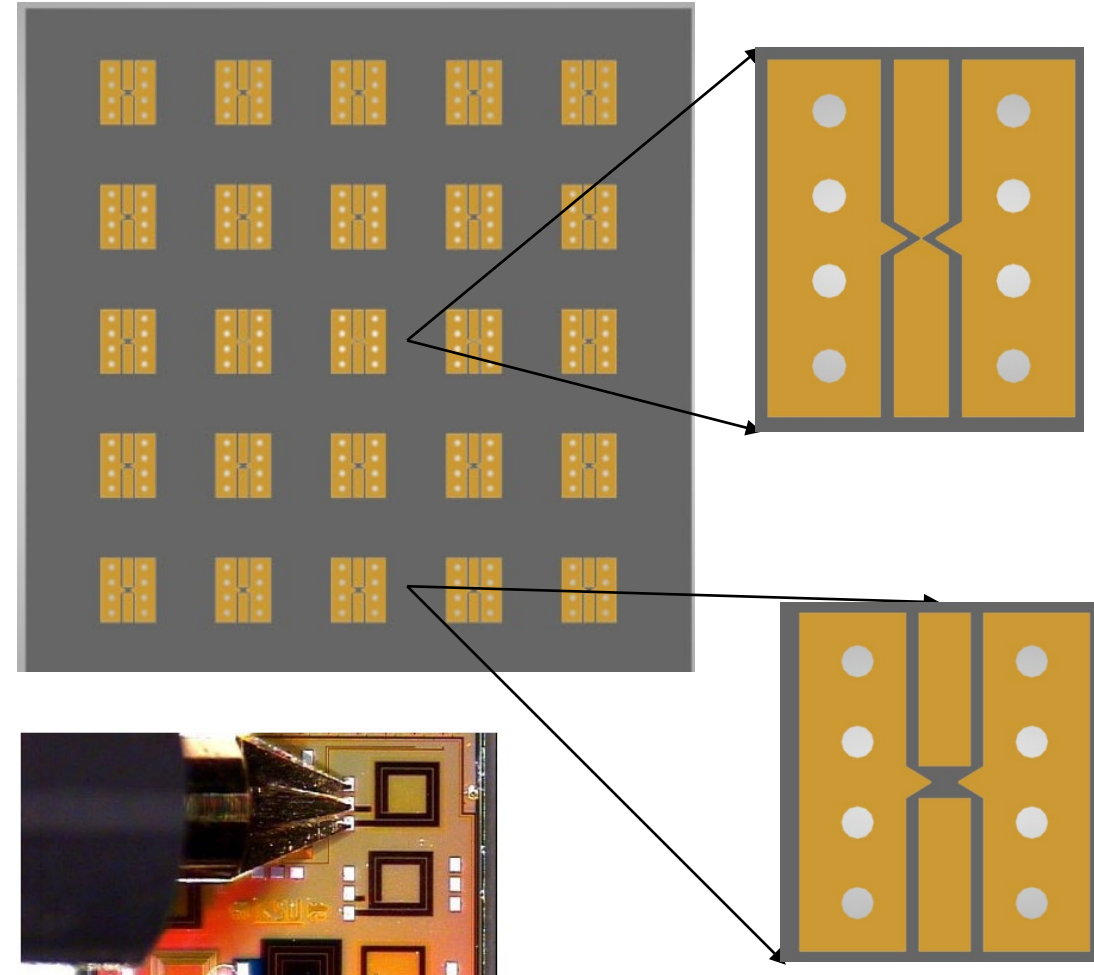
Memristive RF switch in 6G technology

Conventional switches (diode, transistor) are **volatile**, dissipate both dynamic (switching event) and static energy (required hold voltage).



$$F = 1/2\pi R_{LRS} C_{HRS}$$

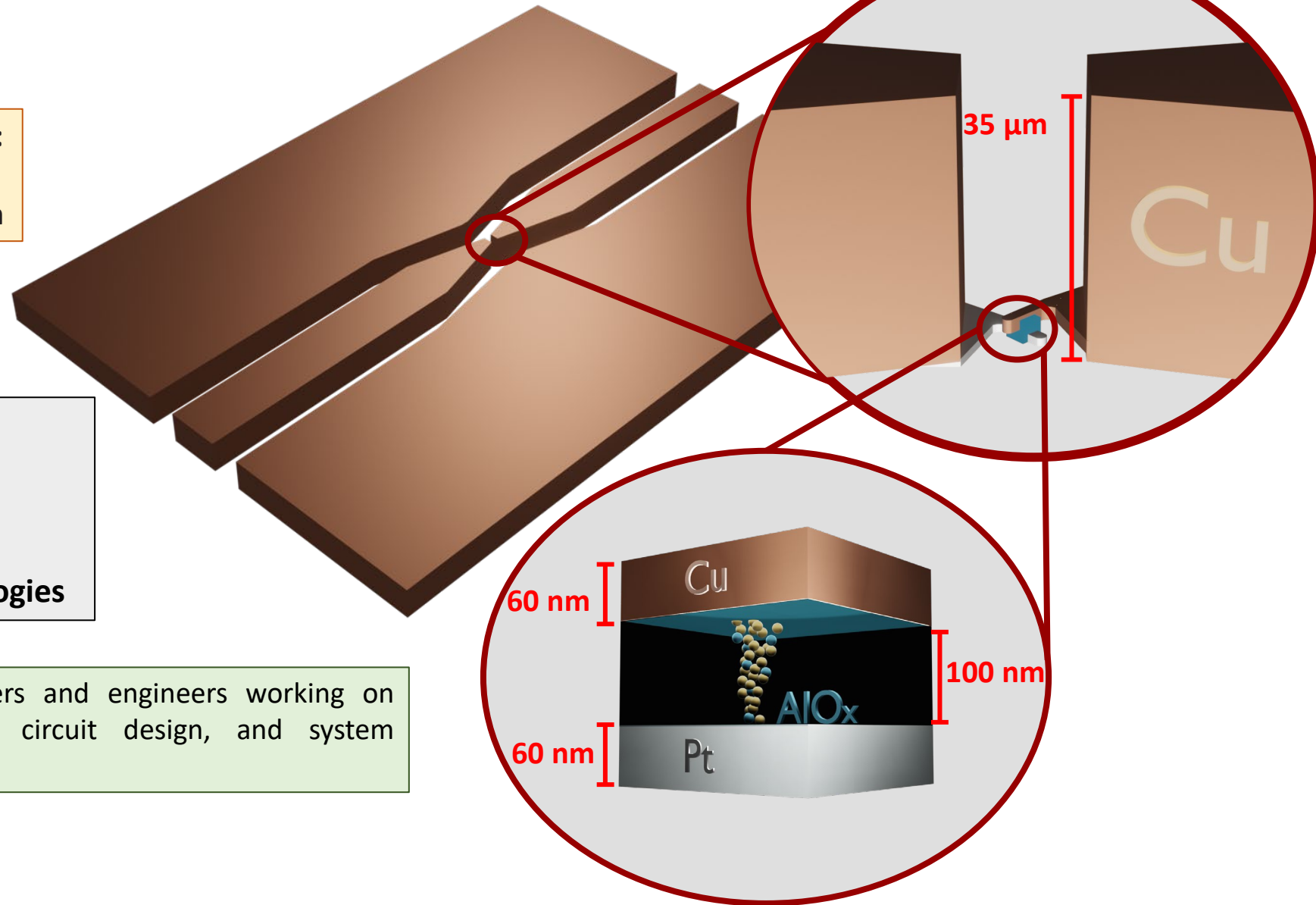
$R_{LRS} \ll 50 \Omega$ Insertion loss
 $C_{HRS} \sim 20 \text{ fF}/\mu\text{m}^2$ Isolation



Challenges of memristive RF switch

2D material & Conductive bridge RAM:

Electrochemical conduction mechanism



- Non-idealities
- Temperature sensitivity
- Endurance and reliability
- Cost-effective fabrication
- Integration with existing technologies

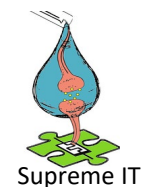
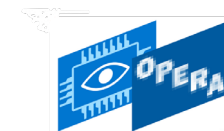
✓ collaborative efforts from researchers and engineers working on materials science, device physics, circuit design, and system integration.

Thank You

This research is funded by FEDER funds through Portuguese Foundation for Science and Technology, under the scope of the projects OPERA Ref. 2022.08132.PTDC, UIDP/50025/2020, doctoral grant DFA/BD/8335/2020, research contract 2021.03386.CEECIND and Supreme IT [EXPL/CTM-REF/0978/2021] of the Associate Laboratory Institute of Nanostructures, Nanomodelling and Nanofabrication – i3N. This work also received funding from the European Community’s H2020 program under grant agreements (SYNERGY, H2020-WIDESPREAD-2020-5, CSA), 101008701 (EMERGE, H2020-INFRAIA-2020-1) and European project of TERRAMETA project with grant agreement of 101097101.



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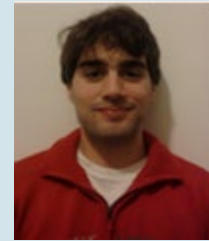
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Prof. Pedro
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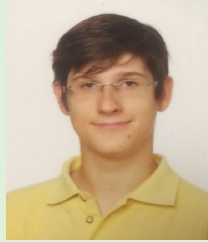
Dr. Emanuel
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Dr. Jorge
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Dr. Adam
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Raquel
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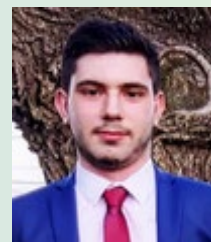
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Tomas
Mintages



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Guilherme
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